## PHOTOSENSITIVE COMPOSITION AND PHOTOSENSITIVE PLANOGRAPHIC PRINTING PLATE

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Inventor(s): HATTORI RYOJI: KUROKI TAKAAKI: MAEHASHI TATSUICHI: KAWAKAMI SOTA

KONISHIROKU PHOTO IND

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## Abstract of JP 10097067 (A)

PROBLEM TO BE SOLVED: To obtain a photosensitive planographic printing plate having improve ink receptivity and chemical resistance without deteriorating sensitivity and developability and to obtain a photosensitive compsn. fit for the photosensitive layer of the printing plate. SOLUTION: The objective photosensitive compsn. contains a monomer represented by the formula CH2 = C(R1) + COQ(CH2) n - C-In R, an oligomer or prepolymer having constituent units formed from the monomer or further contains a high molecular polymer having an unsatid. or sald, group and a phenyl group in a side chain and having a wt. average mol.wt. of 8gt;=10,000 and 8gt;=80 deg.C glass transition temp. In the formula, R is a substituent such as an unsatid. group, unsubsid. alkyl, hydroxyalkyl or carboxyalkyl, (m) is an integer of 8gt;=2, (n) is an integer of 8gt;=3 and R1 is H or methyl; The objective photosensitive planographic printing plate has a photosensitive layer made of the photosensitive compsn.

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